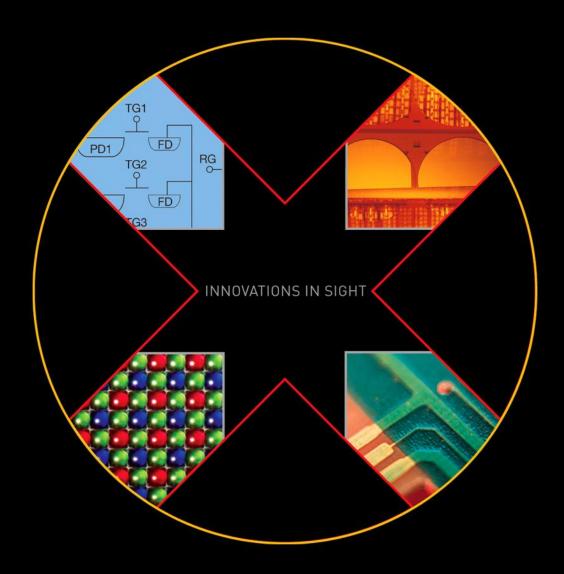
DEVICE PERFORMANCE SPECIFICATION

Revision 1.0 MTD/PS-1134

October 12, 2009



KODAK KAI-08050 IMAGE SENSOR

3296 (H) X 2472 (V) INTERLINE CCD IMAGE SENSOR





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SUMMARY SPECIFICATION

KODAK KAI-08050 IMAGE SENSOR

3296 (H) X 2472 (V) PROGRESSIVE SCAN INTERLINE CCD IMAGE SENSOR

DESCRIPTION

The KODAK KAI-08050 Image Sensor is an 8-megapixel CCD in a 4/3" (22 mm diagonal) optical format. Based on the KODAK TRUESENSE 5.5 micron Interline Transfer CCD Platform, the sensor features broad dynamic range, excellent imaging performance, and a flexible readout architecture that enables use of 1, 2, or 4 outputs. The sensor supports full resolution readout up to 16 frames per second, while a Region of Interest (ROI) mode supports partial readout of the sensor at even higher frame rates. A vertical overflow drain structure suppresses image blooming and enables electronic shuttering for precise exposure control. Other features include low dark current, negligible lag and low smear.

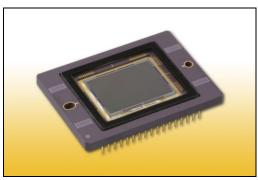
The sensor shares common pin-out and electrical configurations with other devices based on the KODAK TRUESENSE 5.5 micron Interline Transfer Platform, allowing a single camera design to support multiple members of this sensor family.

FEATURES

- Color or Monochrome configurations
- Progressive scan readout
- Flexible readout architecture
- High frame rate
- High sensitivity
- Low noise architecture
- Excellent smear performance
- Package pin reserved for device identification

APPLICATIONS

- Industrial Imaging
- Medical Imaging
- Security



Parameter	Typical Value
Architecture	Interline CCD; Progressive Scan
Total Number of Pixels	3364 (H) x 2520 (V)
Number of Effective Pixels	3320 (H) x 2496 (V)
Number of Active Pixels	3296 (H) x 2472 (V)
Pixel Size	5.5 μm (H) x 5.5 μm (V)
Active Image Size	18.13mm (H) x 13.60mm (V) 22.66mm (diag) 4/3" optical format
Aspect Ratio	4:3
Number of Outputs	1, 2, or 4
Charge Capacity	20,000 electrons
Output Sensitivity	34 μV/e ⁻
Quantum Efficiency KAI-08050-ABA KAI-0850-CBA	50 % (500 nm) 31%, 42%, 43% (620, 540, and 470 nm)
Read Noise (f= 40MHz)	12 electrons rms
Dark Current Photodiode VCCD	7 electrons/s 140 electrons/s
Dark Current Doubling Temp Photodiode VCCD	7 °C 9 °C
Dynamic Range	64 dB
Charge Transfer Efficiency	0.999999
Blooming Suppression	> 300 X
Smear	-100 dB
Image Lag	< 10 electrons
Maximum Pixel Clock Speed	40 MHz
Maximum Frame Rates	
Quad Output	16 fps
Dual Output	8 fps
Single Output	4 fps
Package	68 pin PGA
Cover Glass	AR Coated, 2 Sides
All	T /00 C

All parameters are specified at T = 40° C unless otherwise noted.



ORDERING INFORMATION

Catalog Number	Product Name	Description	Marking Code
4H2073	KAI-08050-AAA-JR-BA	Monochrome, No Microlens, PGA Package, Taped Clear Cover Glass with AR coating (both sides), Standard Grade	KAI-08050-AAA
4H2074	KAI-08050-AAA-JR-AE	Monochrome, No Microlens, PGA Package, Taped Clear Cover Glass with AR coating (both sides), Engineering Grade	Serial Number
4H2075	KAI-08050-ABA-JD-BA	Monochrome, Telecentric Microlens, PGA Package, Sealed Clear Cover Glass with AR coating (both sides), Standard Grade	
4H2076	KAI-08050-ABA-JD-AE	Monochrome, Telecentric Microlens, PGA Package, Sealed Clear Cover Glass with AR coating (both sides), Engineering Grade	KAI-08050-ABA
4H2077	KAI-08050-ABA-JR-BA	Monochrome, Telecentric Microlens, PGA Package, Taped Clear Cover Glass with AR coating (both sides), Standard Grade	Serial Number
4H2078	KAI-08050-ABA-JR-AE	Monochrome, Telecentric Microlens, PGA Package, Taped Clear Cover Glass with AR coating (both sides), Engineering Grade	
4H2079	KAI-08050-CBA-JD-BA	Color (Bayer RGB), Telecentric Microlens, PGA Package, Sealed Clear Cover Glass with AR coating (both sides), Standard Grade	KAI-08050-CBA
4H2080	KAI-08050-CBA-JD-AE	Color (Bayer RGB), Telecentric Microlens, PGA Package, Sealed Clear Cover Glass with AR coating (both sides), Engineering Grade	Serial Number

See ISS Application Note "Product Naming Convention" (MTD/PS-0892) for a full description of naming convention used for KODAK image sensors.

For all reference documentation, please visit our Web Site at www.kodak.com/go/imagers.

Please address all inquiries and purchase orders to:

Image Sensor Solutions Eastman Kodak Company Rochester, New York 14650-2010

Phone: (585) 722-4385 Fax: (585) 477-4947 E-mail: imagers@kodak.com

Kodak reserves the right to change any information contained herein without notice. All information furnished by Kodak is believed to be accurate.



DEVICE DESCRIPTION

ARCHITECTURE

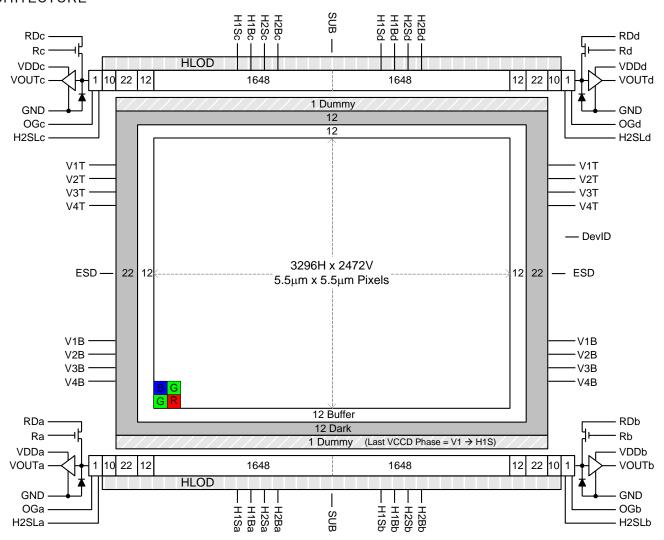


Figure 1: Block Diagram



DARK REFERENCE PIXELS

There are 12 dark reference rows at the top and 12 dark rows at the bottom of the image sensor. The dark rows are not entirely dark and so should not be used for a dark reference level. Use the 22 dark columns on the left or right side of the image sensor as a dark reference.

Under normal circumstances use only the center 20 columns of the 22 column *dark reference* due to potential light leakage.

DUMMY PIXELS

Within each horizontal shift register there are 11 leading additional shift phases. These pixels are designated as *dummy pixels* and should not be used to determine a dark reference level.

In addition, there is one dummy row of pixels at the top and bottom of the image.

ACTIVE BUFFER PIXELS

12 unshielded pixels adjacent to any leading or trailing dark reference regions are classified as *active buffer pixels*. These pixels are light sensitive but are not tested for defects and non-uniformities.

IMAGE ACQUISITION

An electronic representation of an image is formed when incident photons falling on the sensor plane create electron-hole pairs within the individual silicon photodiodes. These photoelectrons are collected locally by the formation of potential wells at each photosite. Below photodiode saturation, the number of photoelectrons collected at each pixel is linearly dependent upon light level and exposure time and nonlinearly dependent on wavelength. When the photodiodes charge capacity is reached, excess electrons are discharged into the substrate to prevent blooming

ESD PROTECTION

Adherence to the power-up and power-down sequence is critical. Failure to follow the proper power-up and power-down sequences may cause damage to the sensor. See Power Up and Power Down Sequence section



PHYSICAL DESCRIPTION

Pin Description and Device Orientation

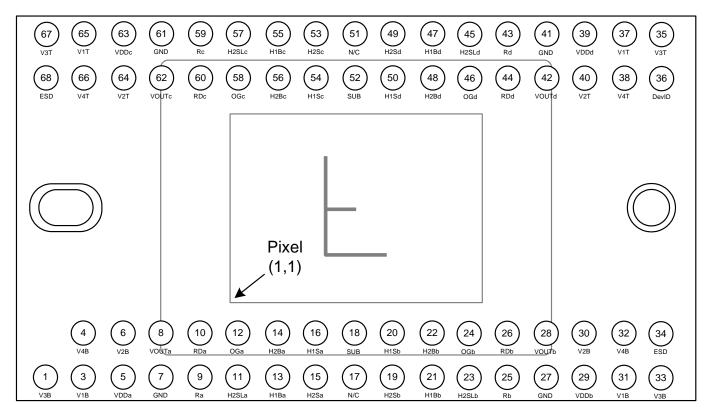


Figure 2: Package Pin Designations - Top View



Pin	Name	Description
1	V3B	Vertical CCD Clock, Phase 3, Bottom
3	V1B	Vertical CCD Clock, Phase 1, Bottom
4	V4B	Vertical CCD Clock, Phase 4, Bottom
5	VDDa	Output Amplifier Supply, Quadrant a
6	V2B	Vertical CCD Clock, Phase 2, Bottom
7	GND	Ground
8	VOUTa	Video Output, Quadrant a
9	Ra	Reset Gate, Quadrant a
10	RDa	Reset Drain, Quadrant a
11	H2SLa	Horizontal CCD Clock, Phase 2, Storage, Last Phase, Quadrant a
12	OGa	Output Gate, Quadrant a
13	H1Ba	Horizontal CCD Clock, Phase 1, Barrier, Quadrant a
14	H2Ba	Horizontal CCD Clock, Phase 2, Barrier, Quadrant a
15	H2Sa	Horizontal CCD Clock, Phase 2, Storage, Quadrant a
16	H1Sa	Horizontal CCD Clock, Phase 1, Storage, Quadrant a
17	N/C	No Connect
18	SUB	Substrate
19	H2Sb	Horizontal CCD Clock, Phase 2, Storage, Quadrant b
20	H1Sb	Horizontal CCD Clock, Phase 1, Storage, Quadrant b
21	H1Bb	Horizontal CCD Clock, Phase 1, Barrier, Quadrant b
22	H2Bb	Horizontal CCD Clock, Phase 2, Barrier, Quadrant b
23	H2SLb	Horizontal CCD Clock, Phase 2, Storage, Last Phase, Quadrant b
24	OGb	Output Gate, Quadrant b
25	Rb	Reset Gate, Quadrant b
26	RDb	Reset Drain, Quadrant b
27	GND	Ground
28	VOUTb	Video Output, Quadrant b
29	VDDb	Output Amplifier Supply, Quadrant b
30	V2B	Vertical CCD Clock, Phase 2, Bottom
31	V1B	Vertical CCD Clock, Phase 1, Bottom
32	V4B	Vertical CCD Clock, Phase 4, Bottom
33	V3B	Vertical CCD Clock, Phase 3, Bottom
34	ESD	ESD Protection Disable

Pin	Name	Description
68	ESD	ESD Protection Disable
67	V3T	Vertical CCD Clock, Phase 3, Top
66	V4T	Vertical CCD Clock, Phase 4, Top
65	V1T	Vertical CCD Clock, Phase 1, Top
64	V2T	Vertical CCD Clock, Phase 2, Top
63	VDDc	Output Amplifier Supply, Quadrant c
62	VOUTc	Video Output, Quadrant c
61	GND	Ground
60	RDc	Reset Drain, Quadrant c
59	Rc	Reset Gate, Quadrant c
58	OGc	Output Gate, Quadrant c
57	H2SLc	Horizontal CCD Clock, Phase 2, Storage, Last Phase, Quadrant c
56	H2Bc	Horizontal CCD Clock, Phase 2, Barrier, Quadrant c
55	H1Bc	Horizontal CCD Clock, Phase 1, Barrier, Quadrant c
54	H1Sc	Horizontal CCD Clock, Phase 1, Storage, Quadrant c
53	H2Sc	Horizontal CCD Clock, Phase 2, Storage, Quadrant c
52	SUB	Substrate
51	N/C	No Connect
50	H1Sd	Horizontal CCD Clock, Phase 1, Storage, Quadrant d
49	H2Sd	Horizontal CCD Clock, Phase 2, Storage, Quadrant d
48	H2Bd	Horizontal CCD Clock, Phase 2, Barrier, Quadrant d
47	H1Bd	Horizontal CCD Clock, Phase 1, Barrier, Quadrant d
46	OGd	Output Gate, Quadrant b
45	H2SLd	Horizontal CCD Clock, Phase 2, Storage, Last Phase, Quadrant d
44	RDd	Reset Drain, Quadrant d
43	Rd	Reset Gate, Quadrant d
42	VOUTd	Video Output, Quadrant d
41	GND	Ground
40	V2T	Vertical CCD Clock, Phase 2, Top
39	VDDd	Output Amplifier Supply, Quadrant d
38	V4T	Vertical CCD Clock, Phase 4, Top
37	V1T	Vertical CCD Clock, Phase 1, Top
36	DevID	Device Identification
35	V3T	Vertical CCD Clock, Phase 3, Top

Notes:

Liked named pins are internally connected and should have a common drive signal. N/C pins (17, 51) should be left floating.



IMAGING PERFORMANCE

TYPICAL OPERATION CONDITIONS

Unless otherwise noted, the Imaging Performance Specifications are measured using the following conditions.

Description	Condition	Notes
Light Source	Continuous red, green and blue LED illumination	1
Operation	Nominal operating voltages and timing	

Notes:

SPECIFICATIONS

Description	Symbol	Min.	Nom.	Max.	Units	Sampling Plan	Temperature Tested At (°C)	Notes	Test
Dark Field Global Non-Uniformity	DSNU	-	-	2.0	mVpp	Die	27, 40		1
Bright Field Global Non- Uniformity		-	2.0	5.0	%rms	Die	27, 40	1	2
Bright Field Global Peak to Peak Non-Uniformity	PRNU	-	5.0	15.0	%рр	Die	27, 40	1	3
Bright Field Center Non- Uniformity		-	1.0	2.0	%rms	Die	27, 40	1	4
Maximum Photoresponse Nonlinearity	NL	-	2	-	%	Design		2	
Maximum Gain Difference Between Outputs	ΔG	-	10	-	%	Design		2	
Maximum Signal Error due to Nonlinearity Differences	ΔNL	-	1	-	%	Design		2	
Horizontal CCD Charge Capacity	HNe	-	55	-	ke⁻	Design			
Vertical CCD Charge Capacity	VNe	-	45	-	ke⁻	Design			
Photodiode Charge Capacity	PNe	=	20	-	ke⁻	Die	27, 40	3	
Horizontal CCD Charge Transfer Efficiency	HCTE	0.999995	0.999999	-		Die			
Vertical CCD Charge Transfer Efficiency	VCTE	0.999995	0.999999	-		Die			
Photodiode Dark Current	lpd	-	7	70	e/p/s	Die	40		
Vertical CCD Dark Current	lvd	=	140	400	e/p/s	Die	40		
Image Lag	Lag	=	=	10	e ⁻	Design			
Antiblooming Factor	Xab	300	-	=		Design			
Vertical Smear	Smr	-	-100	-	dB	Design			
Read Noise	n _{e-T}	-	12	=	e⁻rms	Design		4	
Dynamic Range	DR	-	64	-	dB	Design		4, 5	
Output Amplifier DC Offset	V _{odc}	-	9.4	-	V	Die	27, 40		
Output Amplifier Bandwidth	f _{-3db}	-	250	-	MHz	Die		6	
Output Amplifier Impedance	R _{out}	-	127	-	Ohms	Die	27, 40		
Output Amplifier Sensitivity	ΔV/ΔΝ	-	34	-	μV/e ⁻	Design			

^{1.} For monochrome sensor, only green LED used.



KAI-08050-ABA

Description	Symbol	Min.	Nom.	Max.	Units	Sampling Plan	Temperature Tested At (°C)	Notes	Test
Peak Quantum Efficiency	QE _{max}	-	50	-	%	Design			
Peak Quantum Efficiency Wavelength	λQE	-	500	-	nm	Design			

KAI-08050-CBA

Description		Symbol	Min.	Nom.	Max.	Units	Sampling Plan	Temperature Tested At (°C)	Notes	Test
Peak Quantum Efficiency	Blue Green Red	QE _{max}	-	43 42 31	-	%	Design			
Peak Quantum Efficiency Wavelength	Blue Green Red	λQE	-	470 540 620	-	nm	Design			

Notes:

- Per color
- 2. Value is over the range of 10% to 90% of photodiode saturation.
- 3. The operating value of the substrate voltage, VAB, will be marked on the shipping container for each device. The value of VAB is set such that the photodiode charge capacity is 680 mV.
- 4. At 40 MHz.
- 5. Uses 20LOG(PNe/ n_{e-T})
- 6. Assumes 5pF load



TYPICAL PERFORMANCE CURVES

QUANTUM EFFICIENCY

Monochrome with Microlens

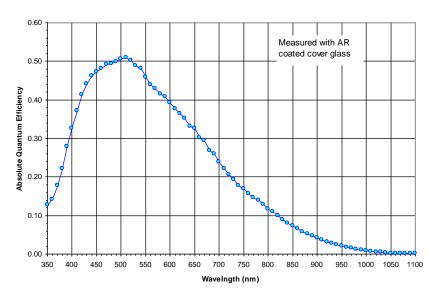


Figure 3: Monochrome with Microlens Quantum Efficiency

Monochrome without Microlens

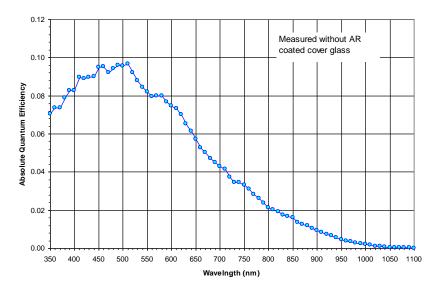


Figure 4: Monochrome without Microlens Quantum Efficiency



Color (Bayer RGB) with Microlens

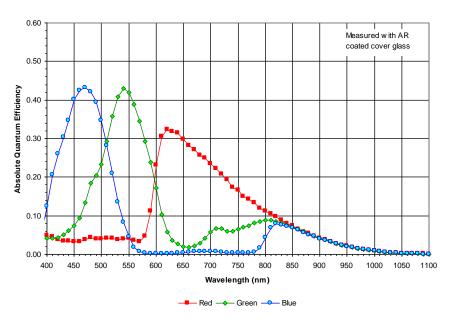


Figure 5: Color with Microlens Quantum Efficiency



ANGULAR QUANTUM EFFICIENCY

For the curves marked "Horizontal", the incident light angle is varied in a plane parallel to the HCCD. For the curves marked "Vertical", the incident light angle is varied in a plane parallel to the VCCD.

Monochrome with Microlens

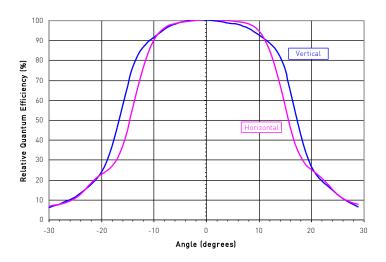


Figure 6: Monochrome with Microlens Angular Quantum Efficiency

DARK CURRENT VERSUS TEMPERATURE

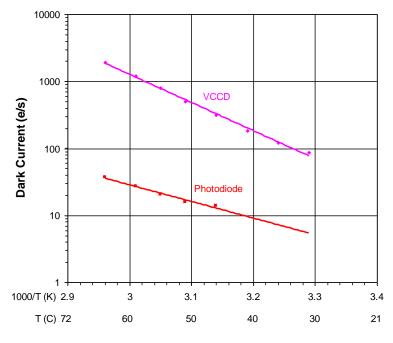


Figure 7: Dark Current versus Temperature



POWER - ESTIMATED

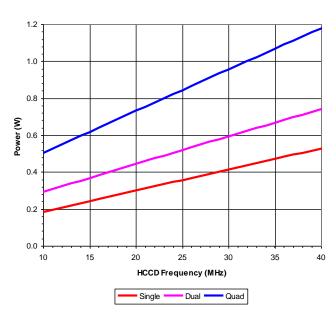


Figure 8: Power

FRAME RATES

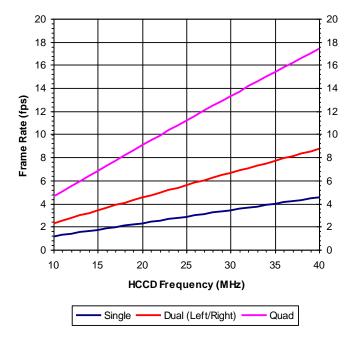


Figure 9: Frame Rates



DEFECT DEFINITIONS

OPERATION CONDITIONS FOR DEFECT TESTING AT 40°C

Description	Condition	Notes
Operational Mode	Two outputs, using VOUTa and VOUTc, continuous readout	
HCCD Clock Frequency	10 MHz	
Pixels Per Line	3520	1
Lines Per Frame	1360	2
Line Time	354.9 μsec	
Frame Time	482.7 msec	
Dhatadiadalata aati a Tiara	Mode A: PD_Tint = Frame Time = 482.7 msec, no electronic shutter used	
Photodiode Integration Time	Mode B: PD_Tint = 33 msec, electronic shutter used	
VCCD Integration Time	447.2 msec	3
Temperature	40°C	
Light Source	Continuous red, green and blue LED illumination	4
Operation	Nominal operating voltages and timing	

Notes

- 1. Horizontal overclocking used
- 2. Vertical overclocking used
- 3. VCCD Integration Time = 1260 lines x Line Time, which is the total time a pixel will spend in the VCCD registers.
- 4. For monochrome sensor, only the green LED is used.

DEFECT DEFINITIONS FOR TESTING AT 40°C

Description	Definition	Standard Grade	Notes	Test
Major dark field defective bright pixel	PD_Tint = Mode A -> Defect >= 166 mV or PD_Tint = Mode B -> Defect >= 12 mV	80	1	5
Major bright field defective dark pixel	Defect >= 12 %			6
Minor dark field defective bright pixel	PD_Tint = Mode A -> Defect >= 86 mV or PD_Tint = Mode B -> Defect >= 6 mV	800		
Cluster defect	A group of 2 to 10 contiguous major defective pixels, but no more than 3 adjacent defects horizontally.	15	2	
A group of more than 10 contiguous Column defect major defective pixels along a single column		0	2	

Notes:

- 1. For the color device (KAI-08050-CBA), a bright field defective pixel deviates by 12% with respect to pixels of the same color.
- 2. Column and cluster defects are separated by no less than two [2] good pixels in any direction (excluding single pixel defects).



OPERATION CONDITIONS FOR DEFECT TESTING AT 27°C

Description	Condition	Notes
Operational Mode	Two outputs, using VOUTa and VOUTc, continuous readout	
HCCD Clock Frequency	20 MHz	
Pixels Per Line	3520	1
Lines Per Frame	1360	2
Line Time	177.8 μsec	
Frame Time	241.8 msec	
Photodiode Integration Time	Mode A: PD_Tint = Frame Time = 241.8 msec, no electronic shutter used	
(PD_Tint)	Mode B: PD_Tint = 33 msec, electronic shutter used	1
VCCD Integration Time	224.0 msec	3
Temperature	27°C	
Light Source	Continuous red, green and blue LED illumination	4
Operation	Nominal operating voltages and timing	

Notes

- 1. Horizontal overclocking used
- 2. Vertical overclocking used
- 3. VCCD Integration Time = 1260 lines x Line Time, which is the total time a pixel will spend in the VCCD registers.
- 4. For monochrome sensor, only the green LED is used.

DEFECT DEFINITIONS FOR TESTING AT 27°C

Description	Definition	Standard Grade	Notes	Test
Major dark field defective bright pixel	PD_Tint = Mode A -> Defect >= 26 mV or PD_Tint = Mode B -> Defect >= 4 mV	80	1	5
Major bright field defective dark pixel	Defect >= 12 %			6
Cluster Defect	A group of 2 to 10 contiguous major defective pixels, but no more than 3 adjacent defects horizontally.	15	2	
Column defect	A group of more than 10 contiguous major defective pixels along a single column	0	2	

Notes:

- 1. For the color device (KAI-08050-CBA), a bright field defective pixel deviates by 12% with respect to pixels of the same color.
- 2. Column and cluster defects are separated by no less than two (2) good pixels in any direction (excluding single pixel defects).

Defect Map

The defect map supplied with each sensor is based upon testing at an ambient (27C) temperature. Minor point defects are not included in the defect map. All defective pixels are reference to pixel 1,1 in the defect maps. See Figure 10: Regions of Interest for the location of pixel 1,1.



TEST DEFINITIONS

TEST REGIONS OF INTEREST

```
Image Area ROI: Pixel 1, 1 to Pixel 3320, 2496 Active Area ROI: Pixel 13, 13 to Pixel 3308, 2484 Center ROI: Pixel 1611, 1199 to Pixel 1710, 1298
```

Only the Active Area ROI pixels are used for performance and defect tests.

OVERCLOCKING

The test system timing is configured such that the sensor is overclocked in both the vertical and horizontal directions. See Figure 10 for a pictorial representation of the regions of interest.

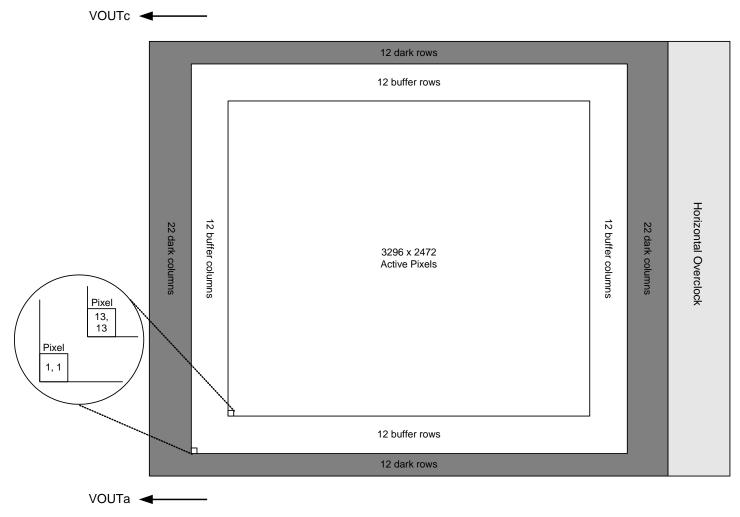


Figure 10: Regions of Interest



TESTS

1. Dark Field Global Non-Uniformity

This test is performed under dark field conditions. The sensor is partitioned into 768 sub regions of interest, each of which is 103 by 103 pixels in size. The average signal level of each of the 768 sub regions of interest is calculated. The signal level of each of the sub regions of interest is calculated using the following formula:

Signal of ROI[i] = (ROI Average in counts – Horizontal overclock average in counts) * mV per count Where i = 1 to 768. During this calculation on the 768 sub regions of interest, the maximum and minimum signal levels are found.

The dark field global uniformity is then calculated as the maximum signal found minus the minimum signal level found.

Units: mVpp (millivolts peak to peak)

2. Global Non-Uniformity

This test is performed with the imager illuminated to a level such that the output is at 70% of saturation (approximately 476 mV). Prior to this test being performed the substrate voltage has been set such that the charge capacity of the sensor is 680 mV. Global non-uniformity is defined as

Global Non - Uniformity = 100 *
$$\left(\frac{\text{Active Area Standard Deviation}}{\text{Active Area Signal}}\right)$$
 Units: %rms

Active Area Signal = Active Area Average - Dark Column Average

3. Global Peak to Peak Non-Uniformity

This test is performed with the imager illuminated to a level such that the output is at 70% of saturation (approximately 476 mV). Prior to this test being performed the substrate voltage has been set such that the charge capacity of the sensor is 680 mV. The sensor is partitioned into 768 sub regions of interest, each of which is 103 by 103 pixels in size. The average signal level of each of the 768 sub regions of interest (ROI) is calculated. The signal level of each of the sub regions of interest is calculated using the following formula:

Signal of ROI[i] = (ROI Average in counts - Horizontal overclock average in counts) * mV per count Where <math>i = 1 to 768. During this calculation on the 768 sub regions of interest, the maximum and minimum signal levels are found.

The global peak to peak uniformity is then calculated as:

Units: %pp



4. Center Non-Uniformity

This test is performed with the imager illuminated to a level such that the output is at 70% of saturation (approximately 476 mV). Prior to this test being performed the substrate voltage has been set such that the charge capacity of the sensor is 680 mV. Defects are excluded for the calculation of this test. This test is performed on the center 100 by 100 pixels of the sensor. Center uniformity is defined as:

Units: %rms

Center ROI Signal = Center ROI Average – Dark Column Average

5. Dark field defect test

This test is performed under dark field conditions. The sensor is partitioned into 768 sub regions of interest, each of which is 103 by 103 pixels in size. In each region of interest, the median value of all pixels is found. For each region of interest, a pixel is marked defective if it is greater than or equal to the median value of that region of interest plus the defect threshold specified in the "Defect Definitions" section.

6. Bright field defect test

This test is performed with the imager illuminated to a level such that the output is at approximately 476 mV. Prior to this test being performed the substrate voltage has been set such that the charge capacity of the sensor is 680 mV. The average signal level of all active pixels is found. The bright and dark thresholds are set as:

Dark defect threshold = Active Area Signal * threshold Bright defect threshold = Active Area Signal * threshold

The sensor is then partitioned into 768 sub regions of interest, each of which is 103 by 103 pixels in size. In each region of interest, the average value of all pixels is found. For each region of interest, a pixel is marked defective if it is greater than or equal to the median value of that region of interest plus the bright threshold specified or if it is less than or equal to the median value of that region of interest minus the dark threshold specified.

Example for major bright field defective pixels:

- Average value of all active pixels is found to be 476 mV
- Dark defect threshold: 476 mV * 12 % = 57 mV
- Bright defect threshold: 476 mV * 12 % = 57 mV
- Region of interest #1 selected. This region of interest is pixels 13, 13 to pixels 115, 115.
 - Median of this region of interest is found to be 470 mV.
 - Any pixel in this region of interest that is >= (470 + 57 mV) 527 mV in intensity will be marked defective.
 - Any pixel in this region of interest that is <= (470 57 mV) 413 mV in intensity will be marked defective.

All remaining 768 sub regions of interest are analyzed for defective pixels in the same manner.



OPERATION

ABSOLUTE MAXIMUM RATINGS

Absolute maximum rating is defined as a level or condition that should not be exceeded at any time per the description. If the level or the condition is exceeded, the device will be degraded and may be damaged. Operation at these values will reduce MTTF.

Description	Symbol	Minimum	Maximum	Units	Notes
Operating Temperature	T _{OP}	-50	+70	°C	1
Humidity	RH	+5	+90	%	2
Output Bias Current	lout	-	60	mA	3
Off-chip Load	Cı	-	10	pF	

Notes:

- 1. Noise performance will degrade at higher temperatures.
- 2. T=25°C. Excessive humidity will degrade MTTF.
- 3. Total for all outputs. Maximum current is -15 mA for each output. Avoid shorting output pins to ground or any low impedance source during operation. Amplifier bandwidth increases at higher current and lower load capacitance at the expense of reduced gain (sensitivity).

ABSOLUTE MAXIMUM VOLTAGE RATINGS BETWEEN PINS AND GROUND

Description	Minimum	Maximum	Units	Notes
VDDα, VOUΤα, RDα	-0.4	17.5	V	1
V1B, V1T	ESD - 0.4	ESD + 24.0	V	
V2B, V2T, V3B, V3T, V4B, V4T	ESD - 0.4	ESD + 14.0	V	
H1Sα, H1Bα, H2Sα, H2Bα, H2SLα, Rα, OGα	ESD - 0.4	ESD + 14.0	V	1
ESD	-10.0	0.0	V	
SUB	-0.4	40.0	V	

Notes:

1. α denotes a, b, c or d



POWER UP AND POWER DOWN SEQUENCE

Adherence to the power-up and power-down sequence is critical. Failure to follow the proper power-up and power-down sequences may cause damage to the sensor.

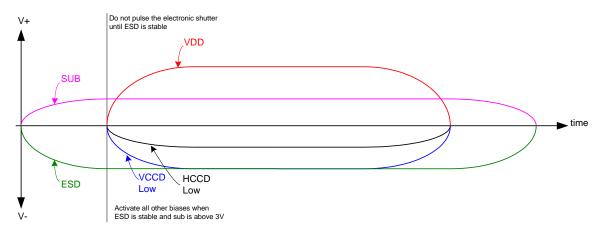
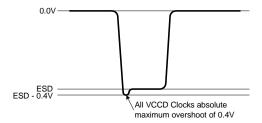


Figure 11: Power Up and Power Down Sequence

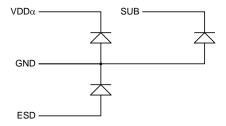
Notes:

- 1. Activate all other biases when ESD is stable and SUB is above 3V
- 2. Do not pulse the electronic shutter until ESD is stable
- 3. VDD cannot be +15V when SUB is 0V
- 4. The image sensor can be protected from an accidental improper ESD voltage by current limiting the SUB current to less than 10mA. SUB and VDD must always be greater than GND. ESD must always be less than GND. Placing diodes between SUB, VDD, ESD and ground will protect the sensor from accidental overshoots of SUB, VDD and ESD during power on and power off. See the figure below.

The VCCD clock waveform must not have a negative overshoot more than 0.4V below the ESD voltage.



Example of external diode protection for SUB, VDD and ESD. α denotes a, b, c or d





DC BIAS OPERATING CONDITIONS

Description	Pins	Symbol	Minimum	Nominal	Maximum	Units	Maximum DC Current	Notes
Reset Drain	$RD \alpha$	RD	+11.8	+12.0	+12.2	V	10μΑ	1
Output Gate	OGα	OG	-2.2	-2.0	-1.8	V	10μΑ	1
Output Amplifier Supply	$VDD \alpha$	VDD	+14.5	+15.0	+15.5	V	11.0 mA	1, 2
Ground	GND	GND	0.0	0.0	0.0	V	-1.0 mA	
Substrate	SUB	VSUB	+5.0	VAB	VDD	V	50μΑ	3
ESD Protection Disable	ESD	ESD	-9.5	-9.0	-8.8	V	50μΑ	6, 7
Output Bias Current	VOUTα	lout	-3.0	-7.0	-10.0	mΑ		1, 4, 5

Notes:

- 1. α denotes a, b, c or d
- 2. The maximum DC current is for one output. Idd = lout + Iss. See Figure 12.
- 3. The operating value of the substrate voltage, VAB, will be marked on the shipping container for each device. The value of VAB is set such that the photodiode charge capacity is the nominal PNe (see Specifications).
- 4. An output load sink must be applied to each VOUT pin to activate each output amplifier.
- 5. Nominal value required for 40MHz operation per output. May be reduced for slower data rates and lower noise.
- 6. Adherence to the power-up and power-down sequence is critical. See Power Up and Power Down Sequence section.
- 7. ESD maximum value must be less than or equal to V1_L+0.4V and V2_L+0.4V

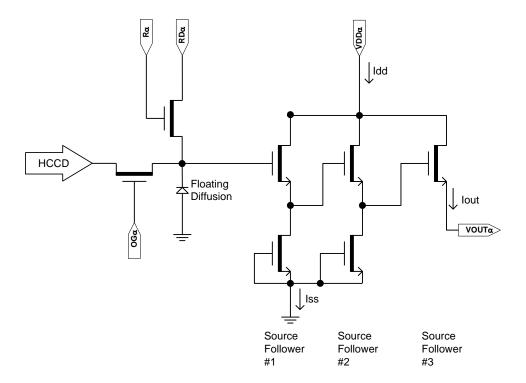


Figure 12: Output Amplifier



AC OPERATING CONDITIONS

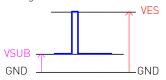
Clock Levels

Description	Pins ¹	Symbol	Level	Minimum	Nominal	Maximum	Units	Capacitance ²
Vertical CCD Clock,		V1_L	Low	-9.5	-9.0	-8.5		
Phase 1	V1B, V1T	V1_M	Mid	-0.2	+0.0	+0.2	V	43 nF
Filase i		V1_H	High	+11.5	+12.0	+12.5		
Vertical CCD Clock,	V2B, V2T	V2_L	Low	-9.5	-9.0	-8.5	V	43 nF
Phase 2	VZD, VZI	V2_H	High	-0.2	+0.0	+0.2	V	45 11F
Vertical CCD Clock,	V3B, V3T	V3_L	Low	-9.5	-9.0	-8.5	V	43 nF
Phase 3	V3D, V31	V3_H	High	-0.2	+0.0	+0.2	V	43 11
Vertical CCD Clock,	V4B, V4T	V4_L	Low	-9.5	-9.0	-8.5	V	43 nF
Phase 4	V4D, V41	V4_H	High	-0.2	+0.0	+0.2	V	43 11
Horizontal CCD Clock,	H1Sα	H1S_L	Low	-4.2	-4.0	-3.8	V	280 pF
Phase 1 Storage	пιзα	H1S_A	Amplitude	+3.8	+4.0	+5.0	٧	2ου μτ
Horizontal CCD Clock,	Η1Βα	H1B_L	Low	-4.2	-4.0	-3.8	V	V 100 pF
Phase 1 Barrier	півα	H1B_A	Amplitude	+3.8	+4.0	+5.0	V	190 pF
Horizontal CCD Clock,	H2Sα	H2S_L	Low	-4.2	-4.0	-3.8	V	280 pF
Phase 2 Storage	пΖЭα	H2S_A	Amplitude	+3.8	+4.0	+5.0	V	2ου μτ
Horizontal CCD Clock,	Η2Βα	H2B_L	Low	-5.2	-4.0	-3.8	V	190 pF
Phase 2 Barrier	пΖВα	H2B_A	Amplitude	+3.8	+4.0	+5.4	V	170 pr
Horizontal CCD Clock,	H2SLα	H2SL_L	Low	-5.2	-5.0	-4.8	\/	20 pF
Last Phase ³	пζэμα	H2SL_A	Amplitude	+4.8	+5.0	+5.2	V	20 μτ
Reset Gate	Rα	R_L ⁴	Low	-3.5	-2.0	-1.5	V	14 pF
neset bate	κα	R_H	High	+2.5	+3.0	+4.0		16 pF
Electronic Shutter	SUB	VES	High	+29.0	+30.0	+40.0	٧	3 nF

Notes:

- 1. α denotes a, b, c or d
- 2. Capacitance is total for all like named pins
- 3. Use separate clock driver for improved speed performance.
- 4. Reset low should be set to –3 volts for signal levels greater than 40,000 electrons.

The figure below shows the DC bias (VSUB) and AC clock (VES) applied to the SUB pin. Both the DC bias and AC clock are referenced to ground.





DEVICE IDENTIFICATION

The device identification pin (DevID) may be used to determine which Kodak 5.5 micron pixel interline CCD sensor is being used.

Description	Pins	Symbol	Minimum	Nominal	Maximum	Units	Maximum DC Current	Notes
Device Identification	DevID	DevID	8,000	10,000	12,000	Ohms	TBD	1, 2, 3

Notes:

- 1. Nominal value subject to verification and/or change during release of preliminary specifications.
- 2. If the Device Identification is not used, it may be left disconnected.
- 3. Values specified are for 40°C.

Recommended Circuit

Note that V1 must be a different value than V2.

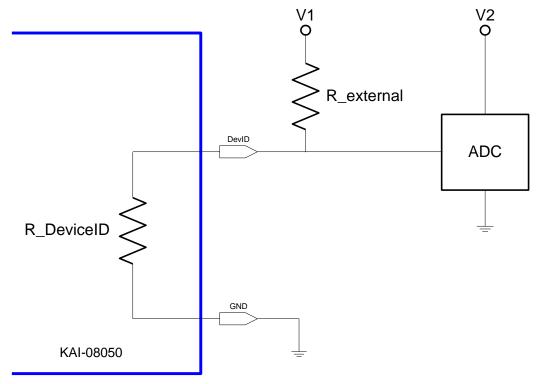


Figure 13: Device Identification Recommended Circuit



TIMING

REQUIREMENTS AND CHARACTERISTICS

Description	Symbol	Minimum	Nominal	Maximum	Units	Notes
Photodiode Transfer	t _{od}	1.0	-	-	μs	
VCCD Leading Pedestal	t _{3p}	4.0	-	-	μs	
VCCD Trailing Pedestal	t _{3d}	4.0	-	-	μs	
VCCD Transfer Delay	t _d	1.0	-	-	μs	
VCCD Transfer	t _v	2.0	-	-	μs	
VCCD Clock Cross-over	V _{VCR}	50	75	100	%	
HCCD Delay	t _{hs}	0.2	=	=	μs	
HCCD Transfer	t _e	25.0	=	=	ns	
Shutter Transfer	t _{sub}	1.0	-	-	μs	
Shutter Delay	t _{hd}	1.0	=	=	μs	
Reset Pulse	t _r	2.5	=	=	ns	
Reset – Video Delay	t _{rv}	=	2.2	=	ns	
H2SL – Video Delay	t _{hv}	=	3.1	=	ns	
Line Time		87.6	=	=		Dual HCCD Readout
Line rime	t _{line}	45.5	-	-	μS	Single HCCD Readout
		57.4	=	=		Quad HCCD Readout
Frame Time	t _{frame}	114.8	=	=	ms	Dual HCCD Readout
		220.7	=	=		Single HCCD Readout

Notes:

Refer to timing diagrams as shown in Figure 14, Figure 15, Figure 16, Figure 17 and Figure 18



TIMING DIAGRAMS

The timing sequence for the clocked device pins may be represented as one of seven patterns (P1-P7) as shown in the table below. The patterns are defined in Figure 14 and Figure 15. Contact Image Sensor Solutions Application Engineering for other readout modes.

	Readout Patterns							
		Dual	Dual	Single				
Device Pin	Quad	VOUTa, VOUTb	VOUTa, VOUTc	VOUTa				
V1T	P1T	P1B	P1T	P1B				
V2T	P2T	P4B	P2T	P4B				
V3T	P3T	P3B	P3T	P3B				
V4T	P4T	P2B	P4T	P2B				
V1B			P1B					
V2B			P2B					
V3B			P3B					
V4B			P4B					
H1Sa			P5					
H1Ba			P0					
H2Sa ²			D/					
H2Ba		P6						
Ra			P7					
H1Sb		P5	P5					
H1Bb		P3	P6					
H2Sb ²		P6	Р	6				
H2Bb		P0	Р	5				
Rb		P7	P7 ¹ or Off ³	P7 ¹ or Off ³				
H1Sc	P5	P5 ¹ or Off ³	P5	P5 ¹ or Off ³				
H1Bc	FJ	F3 01 011	ГЈ	F3 01 011				
H2Sc ²	P6	P6 ¹ or Off ³	P6	P6 ¹ or Off ³				
H2Bc	1 0		1 0					
Rc	P7	P7 ¹ or Off ³	P7	P7 ¹ or Off ³				
H1Sd	P5	P5 ¹ or Off ³	P5	P5 ¹ or Off ³				
H1Bd	1 5	1 3 01 011	P6	1 3 01 011				
H2Sd ²	P6	P6 ¹ or Off ³	P6	P6 ¹ or Off ³				
H2Bd			P5					
Rd	P7	P7 ¹ or Off ³	P7 ¹ or Off ³	P7 ¹ or Off ³				
		1						
# Lines/Frame (Minimum)	1260	2520	1260	2520				
# Pixels/Line	1693 3386							

# Lines/Frame (Minimum)	1260	2520	1260	2520
# Pixels/Line (Minimum)	16	93	33	386

Notes:

- For optimal performance of the sensor. May be clocked at a lower frequency. If clocked at a lower frequency, the frequency selected should be a multiple of the frequency used on the a and b register.
- H2SLx follows the same pattern as H2Sx For optimal speed performance, use a separate clock
- Off = +5V. Note that there may be operating conditions (high temperature and/or very bright light sources) that will cause blooming from the unused c/d register into the image area.



Photodiode Transfer Timing

A row of charge is transferred to the HCCD on the falling edge of V1 as indicated in the P1 pattern below. Using this timing sequence, the leading dummy row or line is combined with the first dark row in the HCCD. The "Last Line" is dependent on readout mode – either 632 or 1264 minimum counts required. It is important to note that, in general, the rising edge of a vertical clock (patterns P1-P4) should be coincident or slightly leading a falling edge at the same time interval. This is particularly true at the point where P1 returns from the high (3rd level) state to the mid state when P4 transitions from the low state to the high state.

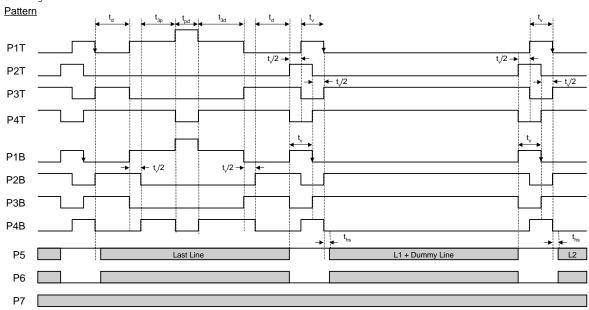


Figure 14: Photodiode Transfer Timing

Line and Pixel Timing

Each row of charge is transferred to the output, as illustrated below, on the falling edge of H2SL (indicated as P6 pattern). The number of pixels in a row is dependent on readout mode – either 853 or 1706 minimum counts required.

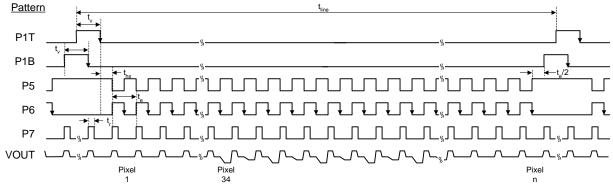


Figure 15: Line and Pixel Timing



Pixel Timing Detail

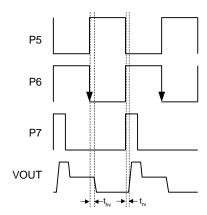
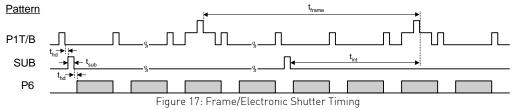


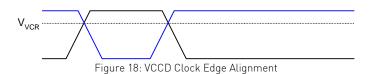
Figure 16: Pixel Timing Detail

Frame/Electronic Shutter Timing

The SUB pin may be optionally clocked to provide electronic shuttering capability as shown below. The resulting photodiode integration time is defined from the falling edge of SUB to the falling edge of V1 (P1 pattern).



VCCD Clock Edge Alignment





Line and Pixel Timing – Vertical Binning by 2

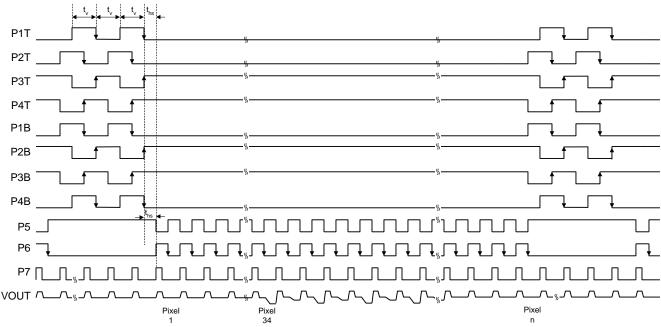


Figure 19: Line and Pixel Timing - Vertical Binning by $\mathbf{2}$



STORAGE AND HANDLING

STORAGE CONDITIONS

Description	Symbol	Minimum	Maximum	Units	Notes
Storage Temperature	T_{ST}	-55	+80	° C	1
Humidity	RH	5	90	%	2

Notes:

- Long-term storage toward the maximum temperature will accelerate color filter degradation.
- 2. T=25° C. Excessive humidity will degrade MTTF.

ESD

- This device contains limited protection against Electrostatic Discharge (ESD). CCD image sensors can be damaged by electrostatic discharge. Failure to do so may alter device performance and reliability.
- 2. Devices should be handled in accordance with strict ESD procedures for Class 0 (<250V per JESD22 Human Body Model test), or Class A (<200V JESD22 Machine Model test) devices. Devices are shipped in static-safe containers and should only be handled at static-safe workstations.
- 3. See Application Note MTD/PS-1039 "Image Sensor Handling and Best Practices" for proper handling and grounding procedures. This application note also contains recommendations for workplace modifications for the minimization of electrostatic discharge.
- 4. Store devices in containers made of electroconductive materials

COVER GLASS CARE AND CLEANLINESS

- 1. The cover glass is highly susceptible to particles and other contamination. Perform all assembly operations in a clean environment.
- 2. Touching the cover glass must be avoided.
- 3. Improper cleaning of the cover glass may damage these devices. Refer to Application Note MTD/PS-1039 "Image Sensor Handling and Best Practices"

ENVIRONMENTAL EXPOSURE

- 1. Do not expose to strong sun light for long periods of time. The color filters and/or microlenses may become discolored. Long time exposures to a static high contrast scene should be avoided. The image sensor may become discolored and localized changes in response may occur from color filter/microlens aging.
- 2. Exposure to temperatures exceeding the absolute maximum levels should be avoided for storage and operation. Failure to do so may alter device performance and reliability.
- 3. Avoid sudden temperature changes.
- 4. Exposure to excessive humidity will affect device characteristics and should be avoided. Failure to do so may alter device performance and reliability.
- 5. Avoid storage of the product in the presence of dust or corrosive agents or gases. Long-term storage should be avoided. Deterioration of lead solderability may occur. It is advised that the solderability of the device leads be re-inspected after an extended period of storage, over one year.

SOLDERING RECOMMENDATIONS

- 1. The soldering iron tip temperature is not to exceed 370°C. Failure to do so may alter device performance and reliability.
- 2. Flow soldering method is not recommended. Solder dipping can cause damage to the glass and harm the imaging capability of the device. Recommended method is by partial heating. Kodak recommends the use of a grounded 30W soldering iron. Heat each pin for less than 2 seconds duration.



MECHANICAL INFORMATION

COMPLETED ASSEMBLY

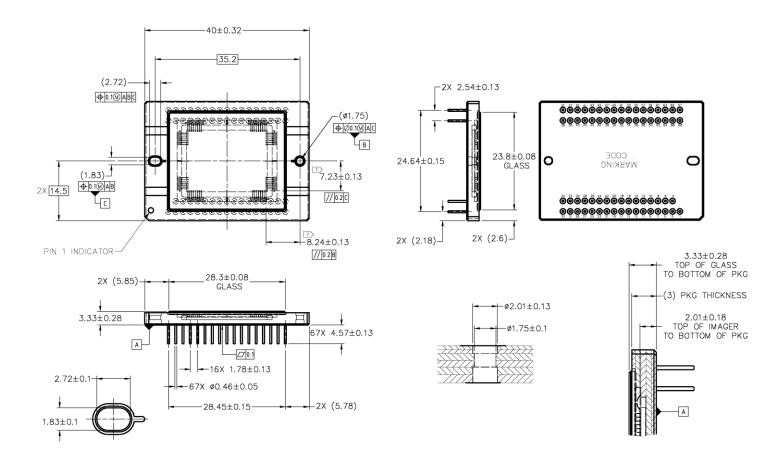


Figure 20: Completed Assembly

Notes:

- 1. See Ordering Information for marking code.
- 2. No materials to interfere with clearance through guide holes.
- 3. The center of the active image is nominally at the center of the package.
- 4. Die rotation < 0.5 degrees
- Internal traces may be exposed on sides of package. Do not allow metal to contact sides of ceramic package.
- Recommended mounting screws:
 1.6 X 0.35 mm (ISO Standard)
 0 80 (Unified Fine Thread Standard)
- 7. Units: MM



COVER GLASS

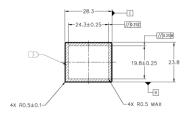




Figure 21: Cover Glass

Notes:

- 1. Dust/Scratch count 12 micron maximum
- 2. Units: MM

COVER GLASS TRANSMISSION

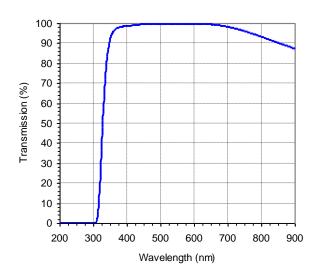


Figure 22: Cover Glass Transmission



QUALITY ASSURANCE AND RELIABILITY

QUALITY STRATEGY

All image sensors will conform to the specifications stated in this document. This will be accomplished through a combination of statistical process control and inspection at key points of the production process. Typical specification limits are not guaranteed but provided as a design target. For further information refer to ISS Application Note "Quality and Reliability" [MTD/PS-0292].

REPLACEMENT

All devices are warranted against failure in accordance with the terms of Terms of Sale. This does not include failure due to mechanical and electrical causes defined as the liability of the customer below.

LIABILITY OF THE SUPPLIER

A reject is defined as an image sensor that does not meet all of the specifications in this document upon receipt by the customer.

LIABILITY OF THE CUSTOMER

Damage from mechanical (scratches or breakage), electrostatic discharge (ESD) damage, or other electrical misuse of the device beyond the stated absolute maximum ratings, which occurred after receipt of the sensor by the customer, shall be the responsibility of the customer.

RELIABILITY

Information concerning the quality assurance and reliability testing procedures and results are available from the Image Sensor Solutions and can be supplied upon request. For further information refer to ISS Application Note "Quality and Reliability" (MTD/PS-0292).

TEST DATA RETENTION

Image sensors shall have an identifying number traceable to a test data file. Test data shall be kept for a period of 2 years after date of delivery.

MECHANICAL

The device assembly drawing is provided as a reference. The device will conform to the published package tolerances.

Kodak reserves the right to change any information contained herein without notice. All information furnished by Kodak is believed to be accurate

WARNING: LIFE SUPPORT APPLICATIONS POLICY

Kodak image sensors are not authorized for and should not be used within Life Support Systems without the specific written consent of the Eastman Kodak Company. Product warranty is limited to replacement of defective components and does not cover injury or property or other consequential damages.



REVISION CHANGES

Revision Number	Description of Changes
1.0	Initial formal release



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